OMB No. 0651-0011
Page 2 of 2

INFORMATION DISCLOSURE STATEMENT	Atty. Docket No.: 150.01160101	Serial No.: 09/653,513
	Applicant(s): Eugene P. Marsh	
	Filing Date: August 31, 2000	Group: 2831

OIPE SCANNED MAR 05 2001 PATENT & TRADEMARK OFFICE

				Niemer, B., et al., "Organometallic chemical vapor deposition of tungsten metal and suppression of carbon incorporation by codeposition of platinum," Appl. Phys. Lett., 61(15):1793-1795 (1992).
				Pathangey et al., "Atomic Layer Deposition for Nanoscale Thin Film Coatings", Vacuum Technology and Coating, pages 32-41, May 2000.
				Takasu, Y., et al., "Preparation of a novel Pt-RuO_2/Ti electrocatalyst by use of highly porous ruthenium oxide support prepared from RuO_2-La_2O_3/electrode," Journal of Alloys and Compounds, 261, 172-175 (1997).
				Versteeg, et al., "Metalorganic Chemical Vapor Deposition by Pulsed Liquid Injection Using an Ultrasonic Nozzle: Titanium Dioxide on Sapphire from Titanium (IV) Isopropoxide", J. Am. Ceram. Soc., 78(10):2763-2768 (1995).
				Precious Metal Labware Catalog from Alfa Aesar, 6 pages.

EXAMINER	Date Considered
	01/03

*Examiner: Initial if citation considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.

Based on Form PTO-FB-A820 Patent and Trademark Office, U.S. Department of Commerce
(Also form PTO-1449)

RECEIVED MAR 7 2001 TC 2800 Mail Room

EXHIBIT A